What is claimed is:

- 1. A heating unit, comprising:
 - a reflector plate made of an opaque quartz; and
- a quartz tube welded to a surface of the reflector plate, wherein a carbon wire which generates heat when a current is applied thereto is inserted in the quartz tube.
- 2. The heating unit of claim 1, wherein the quartz tube 10 is bent.
 - 3. The heating unit of claim 1, wherein the quartz tube is divided and welded to a plurality of zones on the surface of the reflector plate.

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- 4. A mounting table, comprising:
- a heating unit including a reflector plate made of an opaque quartz, and a quartz tube welded to a surface of the reflector plate, wherein a carbon wire which generates heat when a current is applied thereto is inserted in the quartz tube; and
- a mounting table cover member installed to cover the whole quartz tube of the heating unit, a target object being mounted thereon, wherein the mounting table cover member is made of a light absorbing material.

- 5. The mounting table of claim 4, wherein the mounting table cover member is made of SiC.
- 6. A heat treatment apparatus, comprising:
- a mounting table including a heating unit having a reflector plate made of an opaque quartz, and a quartz tube welded to a surface of the reflector plate, wherein a carbon wire which generates heat when a current is applied thereto is inserted in the quartz tube; and a mounting table cover member installed to cover the whole quartz tube of the heating unit, a target object being mounted thereon, wherein the mounting table cover member is made of a light absorbing material;
- a processing chamber accommodating therein the 15 mounting table;
 - a gas supply unit for supplying a gas in the processing chamber; and
 - a vacuum pumping system for evacuating the inside of the processing chamber.

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- 7. A heat treatment apparatus, comprising:
 - a mounting table on which a target object is mounted;
- a processing chamber accommodating therein the mounting table;
- a gas supply unit for supplying a gas in the processing chamber;

- a vacuum pumping system for evacuating the processing chamber; and
- a heating unit installed in the processing chamber to face the mounting table, the heating unit including:
- 5 a reflector plate made of an opaque quartz, and
 - a quartz tube welded to a surface of the reflector plate, wherein a carbon wire which generates heat when a current is applied thereto is inserted in the quartz tube.
- 10 8. The heat treatment apparatus of claim 7, further comprising an additional inner vessel installed to cover an upper side of the mounting table.
 - A heat treatment apparatus, comprising:
- a mounting table on which a target object is mounted;
 - a processing chamber accommodating therein the mounting table;
 - a gas supply unit for supplying a gas in the processing chamber;
- a vacuum pumping system for evacuating the inside of the processing chamber;
 - a target object heating unit for heating the target
 object;
 - an inner vessel installed in the processing chamber;
- a heating unit, installed between the inner vessel and an inner wall of the processing chamber, for heating the

inner vessel,

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wherein the inner vessel is made of a light absorbing material, and

the heating unit includes a reflector plate made of an opaque quartz, and a quartz tube welded to a surface of the reflector plate, a carbon wire which generates heat when a current is applied thereto being inserted in the quartz tube.

- 10. The heat treatment apparatus of claim 9, wherein the inner vessel is made of SiC.
 - 11. The heat treatment apparatus of claim 9 or 10, wherein the target object heating unit is integrally embedded in the mounting table.